REMARKS

The objection raised relative to the Abstract of the Disclosure is not completely understood. A separate single page containing such abstract has been submitted along with the preliminary amendment. For the Examiner's convenience, a copy of that page is enclosed with this Amendment.

The present invention is directed to light transmitting, antistatic thermoplastic molding composition that includes polycarbonate resin and a perfluoroalkylsulfonic acid salt conforming to a particular molecular structure. As presently amended, the claimed salt excludes phosphonium ion salts.

Claims 8-14, 17 and 18 have been rejected under 35 U.S.C. 102(e) as anticipated by, or in the alternative, under 35 U.S.C. 103(a) as obvious over Willems et al, U.S. Patent 6,194,497 (herein Willems).

Willems disclosed antistatic resin compositions containing fluorinated phosphonium sulfonates. As presently amended, the salt entailed in the instant invention excludes such that are based on phosphonium ion.

There is nothing in Willems to suggest the light transmitting antistatic molding composition containing the salts of the present invention.

The present amendment is believed to avoid the Willems document and render the claims patentable thereover.

Claims 8-18 stand rejected under 35 U.S.C. 103(a) said to be obvious over Willems in view of DE 42 22448 (herein Woo) or Hakanson et al, U.S. Patent 4,570,197 (herein Hakanson).

Willems has been discussed above.

Woo disclosed – column 3 lines 17-22- that combining ionioc and nonionic perfluoro surfactants with nonfluorinated copolymerizable radiation curable prepolymers provides improved antistatic compositions that are particularly suitable for forming hard coat layers on optical recording media.

It is not clear why or how Willems that concerns thermoplastic molding compositions may at all be combined with Woo that disclosed curable compositions for any purpose much less for the purpose of a rejection sounding in obviousness in the present context . There is nothing in the record to suggest combining these documents that refer to diverse technologies. Incidentally, the Woo passage

indicated by the Examiner for its purported significance (page 5 line 40) refers to surfactants wherein the cation M is NH_4^+ ; these salts do not describe the "alkylated and/or arylated ammonium ion" salts of the present invention.

The rejection over Willems in view of Woo is asserted to be untenable and its reconsideration and retraction are urged.

Hakanson disclosed reduced electrostatic charge buildup by the application of a coating composition on the surfaces of a molded article. Willems was noted above to disclose antistatic resin compositions that contain fluorinated phosphonium sulfonates. It is not clear why or how the disclosures of these documents may be combined at all, much less for the purpose of a rejection sounding in obviousness in the present context.

The rejection over Willems in view of Hakanson is asserted to be untenable and its reconsideration and retraction are urged.

Claims 8, 9,12,13,17 and 18 stand rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Hisamoto et al (U.S. Patent 4,976,741).

The indication that the embodiment of instant Claim 14 - relating to a molding composition wherein the resin is (co)polycarbonate- is patentable over Hisamoto has been noted. The present amendments to the claims, including restricting the scope of the protection to compositions wherein the resin is (co)polycarbonate is believed to address and overcome the stated rejection.

Believing the above represent a complete response to the Office Action and that the application is in condition for allowance, Applicants request the earliest issuance of an indication to this effect.

Respectfully submitted,

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